

UNITED STATES PATENT AND TRADEMARK OFFICE



UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING	DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/285,773	09/285,773 04/05/1999		GARRY A. MERCALDI	M4065.165/P1	4121
	7590	12/13/2001	•		
THOMAS J		EXAMINER			
DICKSTEIN 2101 L STRE	ET NW	UMEZ ERONINI, LYNETTE T			
WASHINGT	ON, DC 200	371526		ART UNIT	PAPER NUMBER
				1765	
				DATE MAILED: 12/13/2001	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	09/285,773	MERCALDI ET AL.				
Office Action Summary	Examiner	Art Unit				
	Lynette T. Umez-Eronini	1765				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespond nce address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	6(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).				
1) Responsive to communication(s) filed on						
•—	s action is non-final.					
3) Since this application is in condition for allowa closed in accordance with the practice under the						
Disposition of Claims						
4) Claim(s) is/are pending in the application	n.					
4a) Of the abov∈ claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6) Claim(s) is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9) The specification is objected to by the Examiner						
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12)☐ The oath or declaration is objected to by the Exa	aminer.					
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a)-(d) or (f).				
a) ☐ All b) ☐ Scme * c) ☐ None of:						
 Certified copies of the priority documents 	have been received.					
Certified copies of the priority documents	have been received in Application	on No				
 3. Copies of the certified copies of the prior application from the International Bur * See the attached detailed Office action for a list of the certified copies of the prior application. 	eau (PCT Rule 17.2(a)).					
14) Acknowledgment is made of a claim for domestic	·					
a) The translation of the foreign language pro-	visional application has been rec	eived.				
Attachment(s)	, , ,					
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) 🔲 Notice of Informal F	(PTO-413) Paper No(s) Patent Application (PTO-152)				
Polant and Trademark Office						

Art Unit: 1765

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1, 22, and 88 are rejected under 35 U.S.C. 102(b) as being anticipated by Takeuchi (US 5,017,513).

Takeuchi teaches removing a foreign film from a semiconductor structure by immersing the semiconductor structure in a solution of phosphoric acid, hydrofluoric acid and alcohol an alcohol (column 4, lines 25-27). The solution is the same as a non-aqueous composition consisting essentially of two inorganic acids, wherein one of said inorganic acids is selected from the group consisting of phosphoric acid.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Art Unit: 1765

4. Claims 2-7; and 10-11, 13-15 and 33-35 are rejected under 35 U.S.C. 103(a) as being unpatentable over Takeuchi (US 5,017,513) (English abstract of SU 593110A) as applied to claims 1 and 22 respectively.

Takeuchi differs in failing to a specify a polyhydric alcohol as, in claims 2-6, 11, and 26; and the C_2 - C_6 alcohol is selected from the group consisting of ethanol, propanol, iso-butanol and n-butanol, as, in claim 7. Conventional non-aqueous solvents include organic liquids such as alcohols, ketones and esters. Commonly used alcohols include ethylene glycol and propylene glycol.

It would have been obvious to one having ordinary skill in the art at the time of the claimed invention to employ a conventional solvent such as propylene glycol for the purpose of producing an effective etchant.

Takeuchi differs in failing to specify processing variables that are recited in claims 13-15 and 33-35.

It would have been obvious to one having ordinary skill in the art at the time of the claimed invention to employ any of a variety of operational variables such as those claimed by the applicant. They are well-known variables in the etching art and known to affect both the rate and quality of the etching process. Conducting routine experimentation to obtain the best-etched product would optimize the selection of a particular value. Changes in concentrations or other process conditions of an old process do not impart patentability unless the recited ranges are critical, i.e.; they produce a new and unexpected result. *In re Aller et al.*, 105 USPQ 233.

Art Unit: 1765

5. Claims 39-41 and 83 are rejected under 35 U.S.C. 103(a) as being unpatentable over Holoubek J (English title of CS 8801729 A).

Holoubek teaches an etching bath that is a mixture of nitric and hydrofluoric acid, which is diluted with ethylene glycol.

Holoubek differs in failing to explicitly teach the etching composition comprises propylene glycol, in claims 39-41and 83; and isopropanol, in claim 82.

Conventional non-aqueous solvents include organic liquids such as alcohols, ketones and esters. Examples of conventional non-aqueous solvents include isopropanol, ethylene glycol and propylene glycol.

It would have been obvious to one having ordinary skill in the art at the time of the claimed invention to employ a conventional non-aqueous composition such as isopropanol or propylene glycol for the purpose of diluting the etchant.

Holoubek differs in failing to specify processing variables that are recited in claims 39-41.

It would have been obvious to one having ordinary skill in the art at the time of the claimed invention to employ any of a variety of operational variables such as those claimed by the applicant. They are well-known variables in the etching art and known to affect both the rate and quality of the etching process. Conducting routine experimentation to obtain the best-etched product would optimize the selection of a particular value.

Art Unit: 1765

Allowabl Subject Matter

6. Claim 9 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

7. Claims 89-93 are allowed. The following is a statement of reasons for the indication of allowable subject matter: Prior art lacks a teaching of a non-aqueous etching composition consisting essentially of: an alcohol and two inorganic acids are selected from the group consisting of sulfuric, boric, perchloric, carbonic, and sulfurous.

Response to Arguments

8. Applicant's arguments with respect to claims 1-7, 9, 13-15 22-29, 33-35, and 39-41 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

- 9. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Chough (US 3,767,491), Couture et al (US 3,642,549), Hattori et al. (US 5,615,613), and Maeno et al. (US 5,714,407) are relied upon to teach non-aqueous solvents.
- 10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lynette T. Umez-Eronini whose telephone number is 703-306-9074.



Art Unit: 1765

Itue December 12, 2001

> BENJAMIN L. UTECH SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700